

# Free electron laser nitriding of metals: from basic physics to industrial applications

Peter Schaaf <sup>a)</sup>, M. Shinn <sup>b)</sup>, E. Carpene <sup>a)</sup>, J. Kaspar <sup>c)</sup>



GEORG-AUGUST-UNIVERSITÄT  
GÖTTINGEN  
Zweites Physikalisches Institut

a)

**Jefferson Lab**



b)

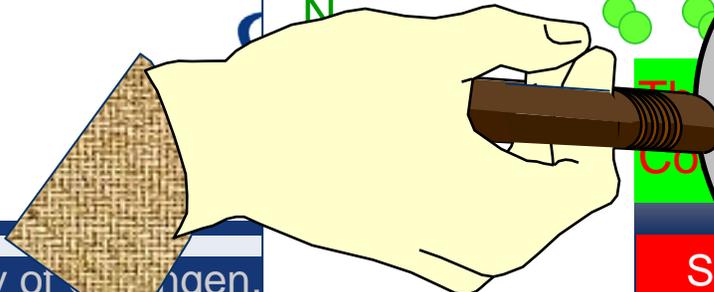
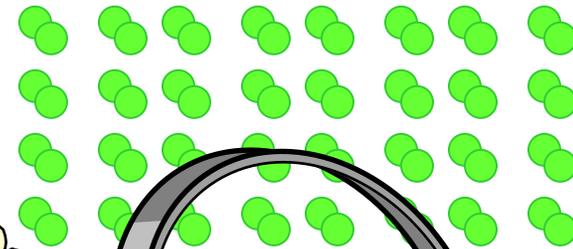
IWS

Fraunhofer  
Institut  
Werkstoff- und  
Strahltechnik

c)

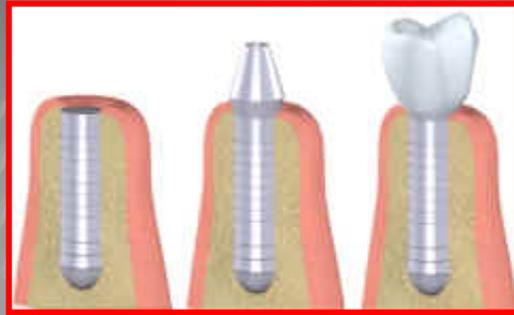
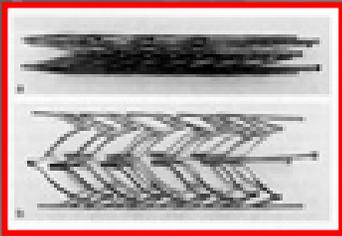
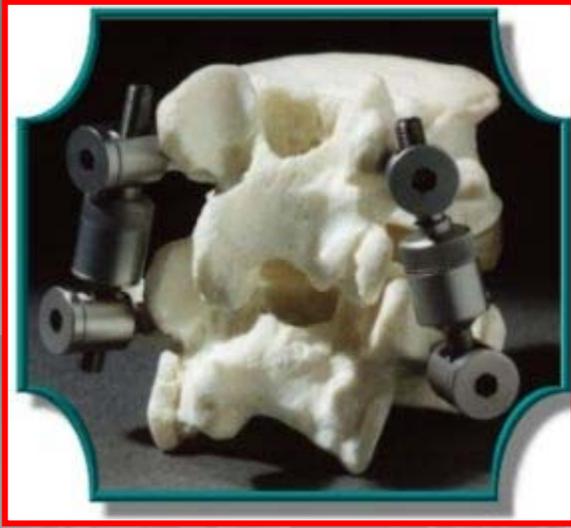
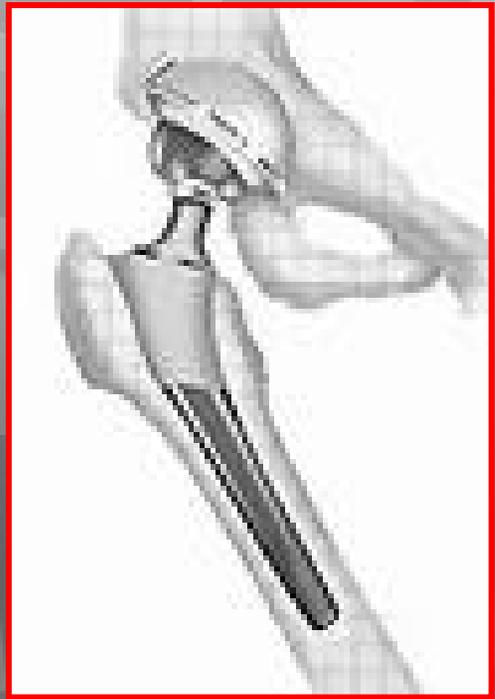
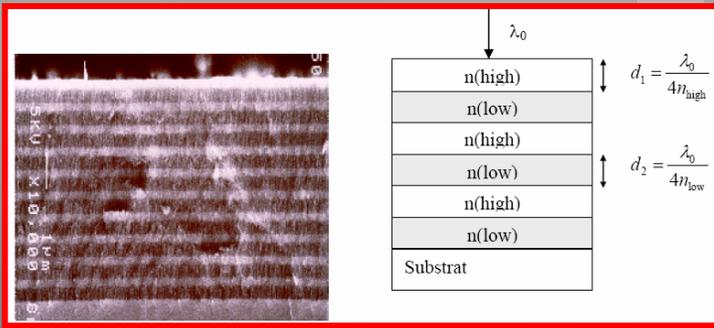
## Laser Nitriding

Reactive or  
non-reactive  
atmosphere



Film or Functional  
Coating: made fast

Substrate, work piece



Precision Components

- Laser Synthesis of Thin Films and Coatings (Nitriding, Carburizing, Hydriding): experimental principles, interactions, melt, plasma, dynamics, diffusion, solidification, ...
  - Fe-N and Fe-C,
  - Austenitic stainless steel
  - **TiN** and TiC
  - AlN and AlC
  - Si<sub>3</sub>N<sub>4</sub> and SiC (IBM-Milliped)
  - Laser-Conditioning of Magnesium
  - Laser-Hydriding Ti-H
  - Production pc-a:Si(H) (TFT)
  - β-FeSi<sub>2</sub> (photovoltaics, optoelectr.)
  - Fe/Ag Multilayers by PLD (GMR, TMR)
  - Polymer-PLD (Applications)
  - Epitaxial recrystallisation (SiC, SiO<sub>2</sub>)

- Excimer Laser    55 ns
- Nd:YAG Laser    8 ns
- **FEL**            1 ps
- Ti:Sapphire    150 fs

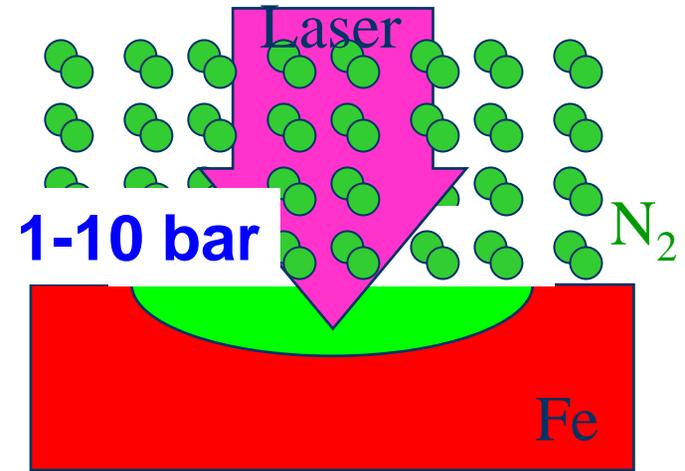
# Basic Physics



# Laser Synthesis: temperature, plasma

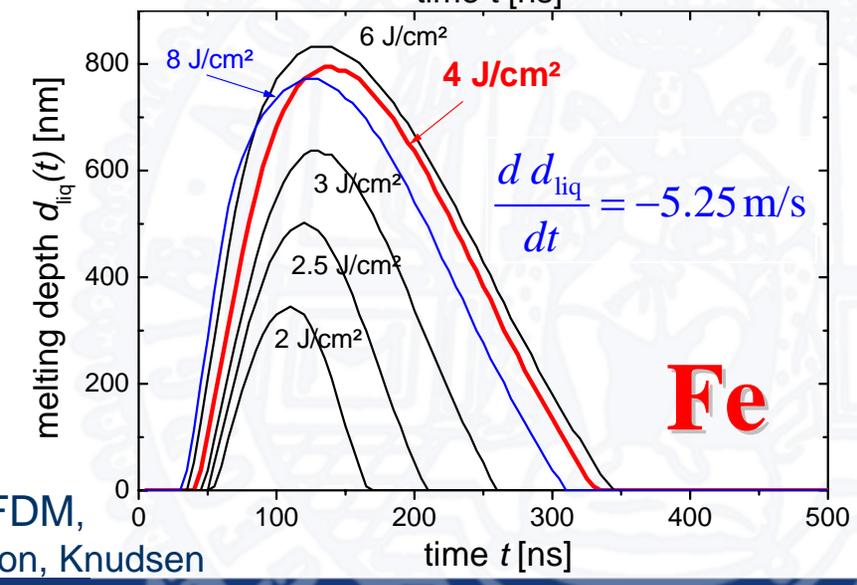
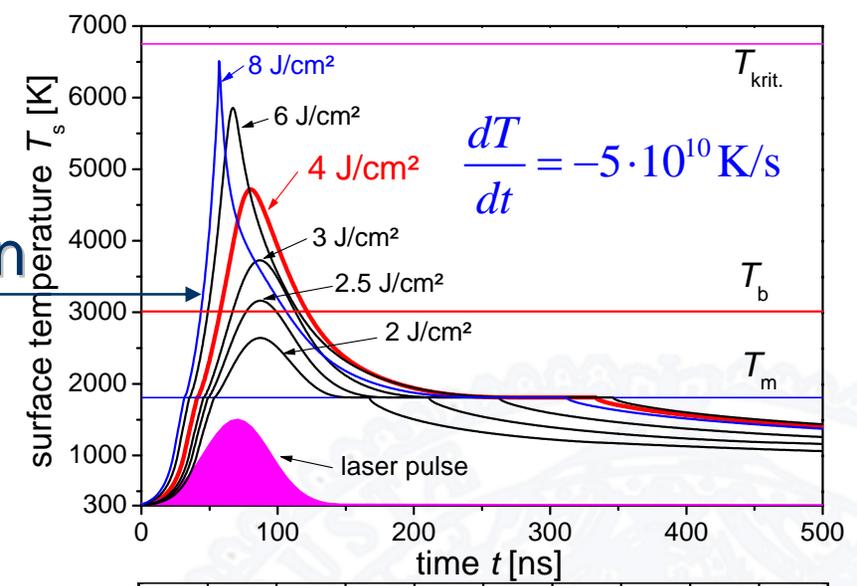
Excimer Laser:  $\lambda=308$  nm (4.03 eV)  
 $t_p=55$  ns (FWHM),  $5 \times 5$  mm<sup>2</sup>,  
 $H=4$  J/cm<sup>2</sup> ( $I_0=70$  MW/cm<sup>2</sup>)

gas transparent for laser



evaporation  
ablation  
plasma-  
formation  
vacuum:  
PLD

but: ambient atmosphere at high pressure  
prevents ablation, causes high  
pressures, chemical reactions,  
take-up into liquid surface, re-solidification,  
coating forms



Numerical: FDM,  
incl. evaporation, Knudsen

# Process: Principle of Laser Synthesis

Hom. Beam

0.1 MPa

0.9 MPa

10

dynamics  
sure,  
s (LSAW)  
tion Wave  
on Wave

Plasma (600 ns) :

Laser pulse: 55 ns

Fe, 1 bar N<sub>2</sub>, 4 J/cm<sup>2</sup>

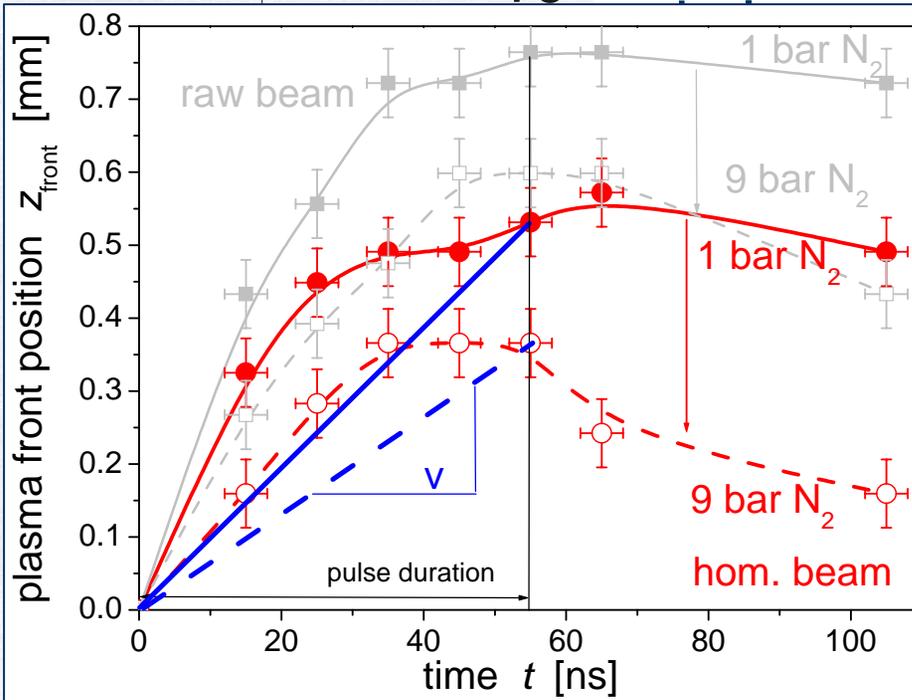
surface

Fe, 9 bar N<sub>2</sub>, 4 J/cm<sup>2</sup>

surface

LSD-model

$$= \left[ 2(\gamma^2 - 1) \cdot \frac{I_0}{\rho_0} \right]^{1/3}$$



Theory

150

Experiment

1 bar :  $v^{\text{LSD}} = 10.4$  km/s

9 bar :  $v^{\text{LSD}} = 5.0$  km/s

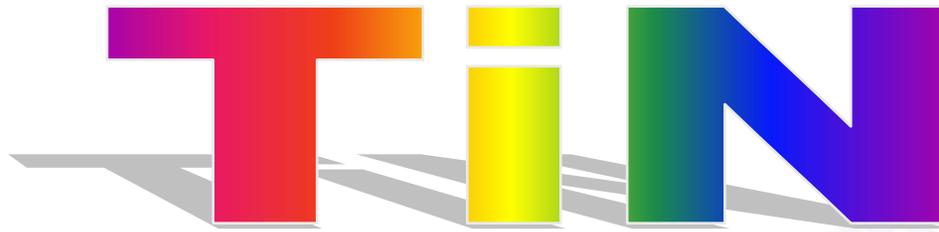
350

1 bar :  $v^{\text{LSD}} = 9.7(16)$  km/s

9 bar :  $v^{\text{LSD}} = 6.6(16)$  km/s

increased gas pressure  $\Rightarrow$  plasma expansion more slowly – Plasma pressure higher and lasts longer!

$p_p$ : 1 bar : 500 bar – 9 bar : 1050 bar



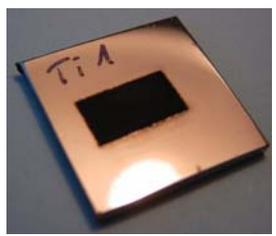
- Irradiation of Ti in  $N_2$
- Free-Electron Laser FEL



# Overview: TiN coatings

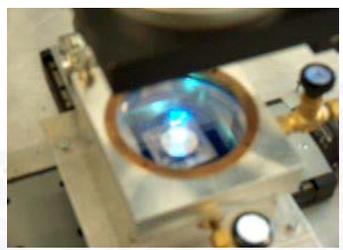
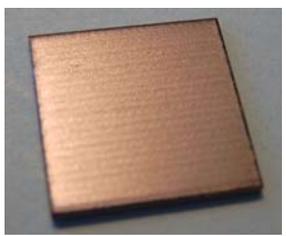
## Ti:Sapphire+CPA

750 nm  
150 fs



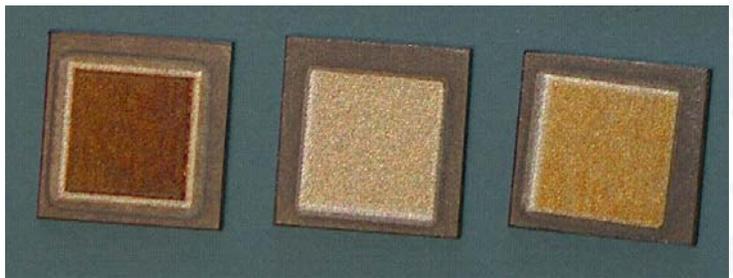
## Excimer Laser

308 nm  
55 ns



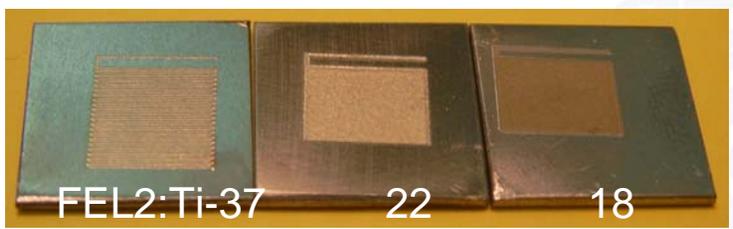
## Nd:YAG

1064 nm, 532 nm  
6 ns



## FEL

3100 nm, 1050 nm  
< 1 ps

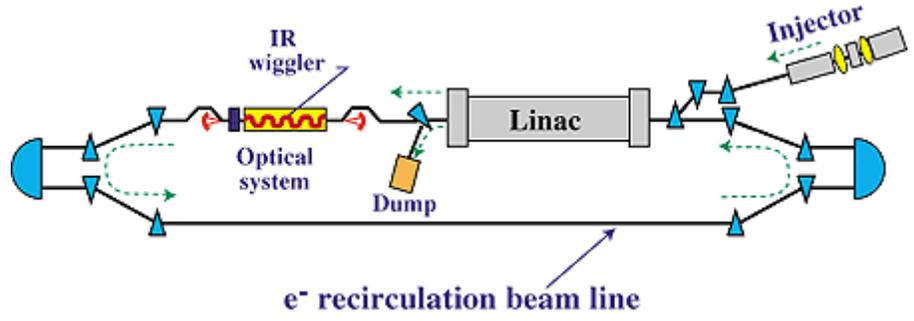
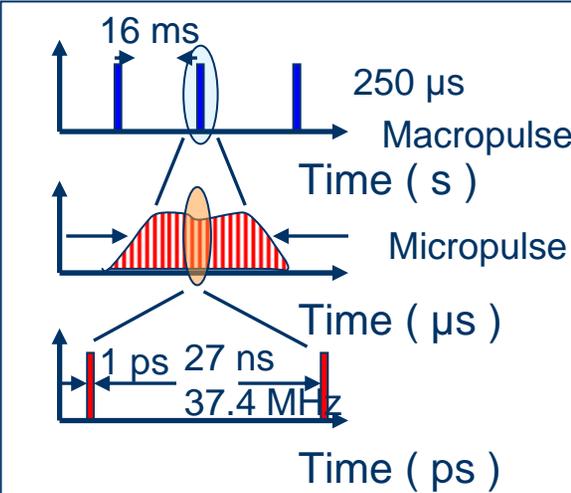
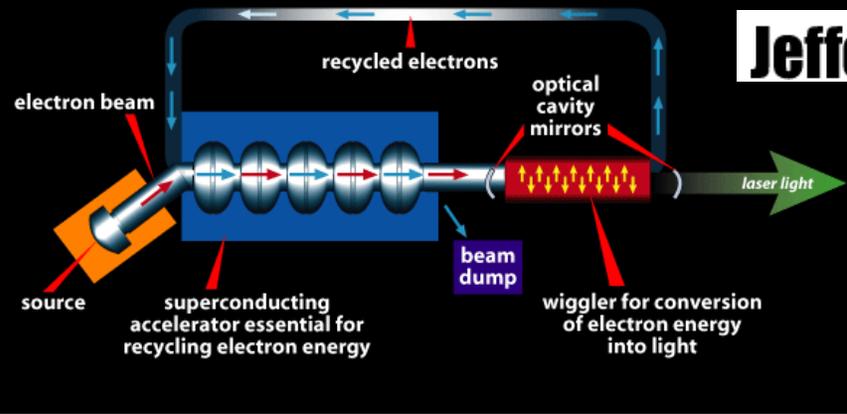




# Faster and better with FEL ?

**Jefferson Lab**

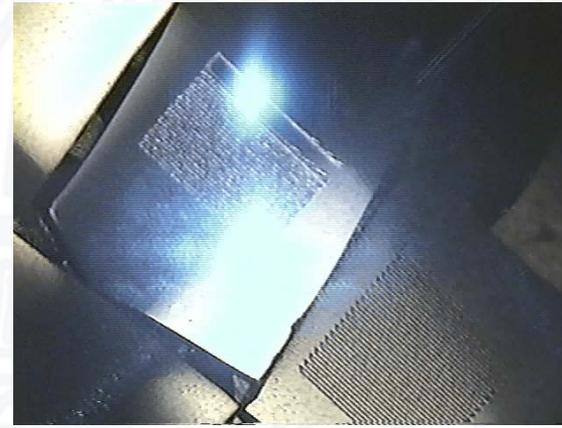
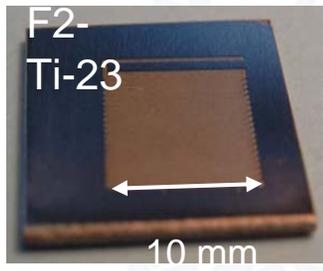
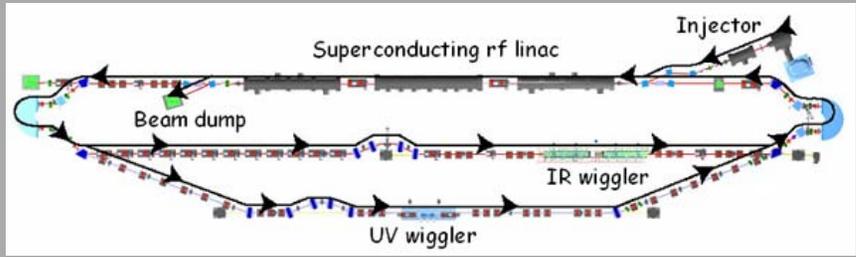
FEL  
Newport News,  
Virginia, USA



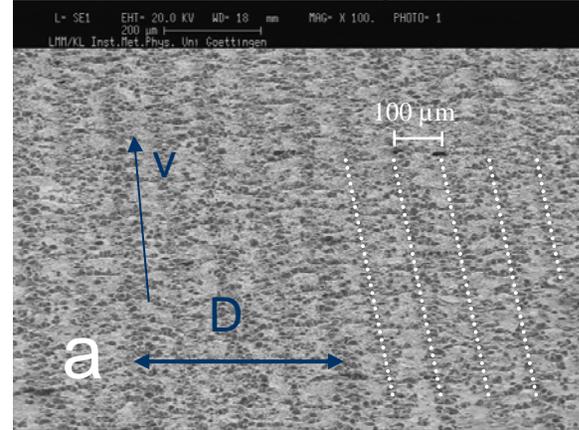
3.1  $\mu\text{m}$   
2 kW

flexible in timing

upgrade: 10 kW, UV (300 nm), 2005

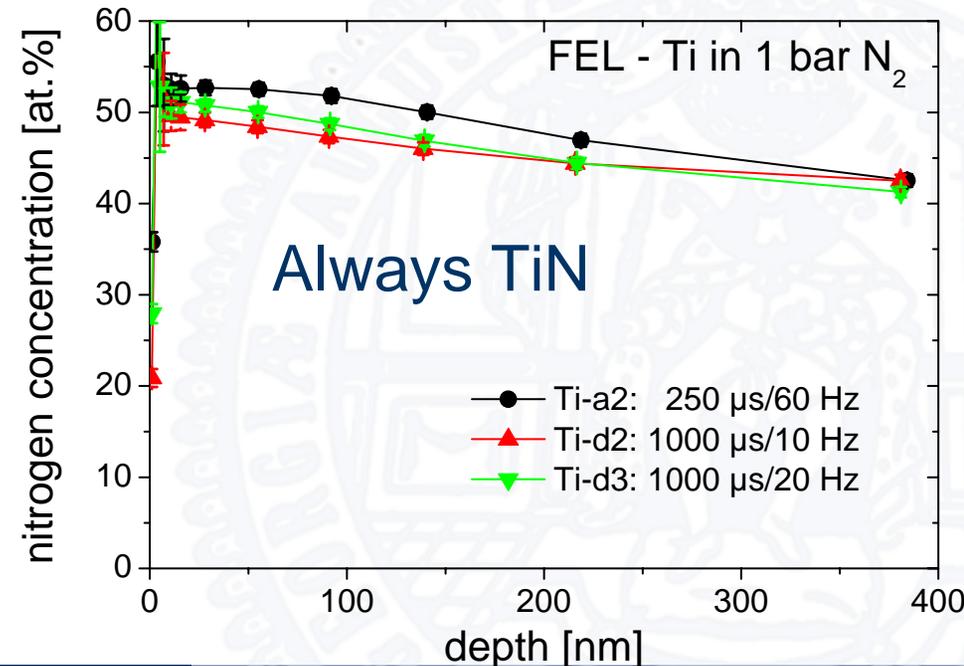


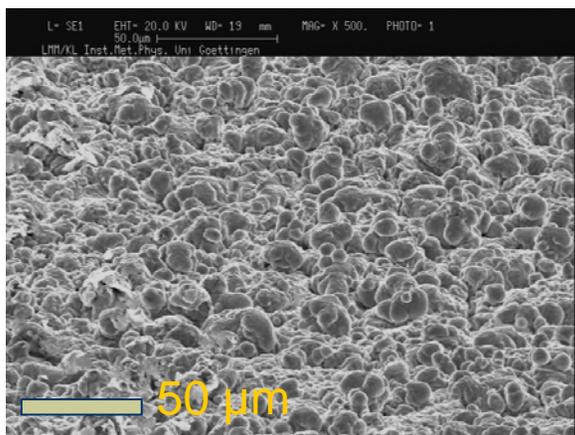
Line scan: velocity  $u=0.5$  mm/s, line width  $D=0.4$  mm, shift  $\delta$  (50, 100, 200  $\mu\text{m}$ )



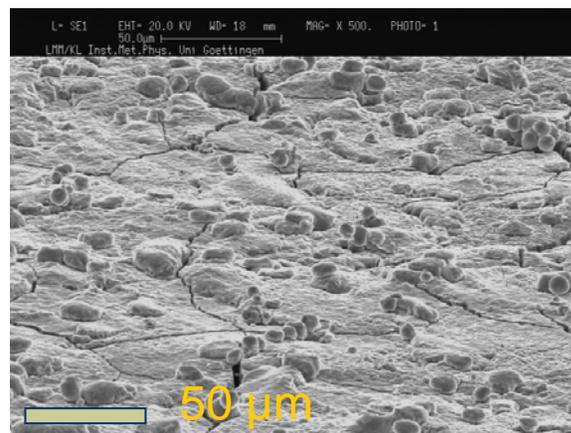
- formation of TiN
- concentration gradient
- independent of parameters
- structure of surface?

Sample	Macro $t_m$ ( $\mu\text{s}$ )	Macro $f_m$ (Hz)	shift $\delta$ ( $\mu\text{m}$ )	Fluence $\phi_m$ ( $\text{J}/\text{cm}^2$ )
Ti-a1	250	60	200	123
Ti-a2	250	60	100	123
Ti-a3	250	60	50	123
Ti-b1	500	30	100	246
Ti-c1	750	30	100	369
Ti-d1	1000	10	200	492
Ti-d2	1000	10	100	492
Ti-d3	1000	20	200	492
Ti-d4	1000	30	200	492
Ti-d5	1000	30	100	492

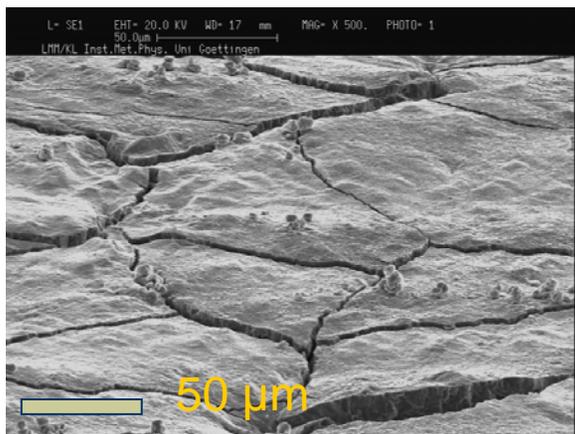




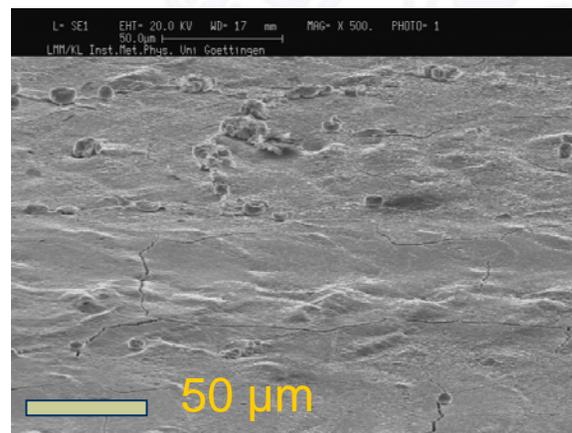
a2: 250  $\mu$ s, 60 Hz, 100 $\mu$ m



c1: 750  $\mu$ s, 30 Hz, 100 $\mu$ m

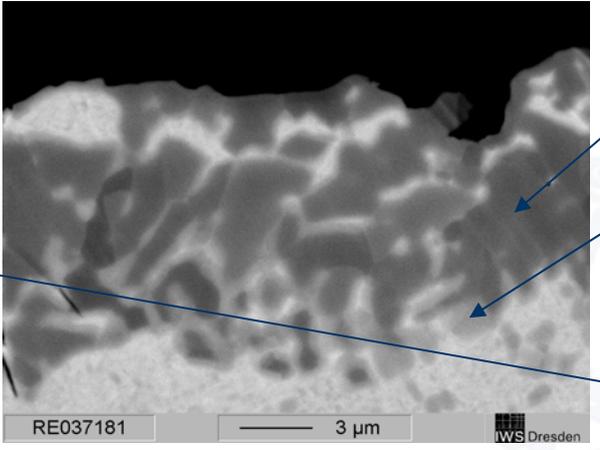
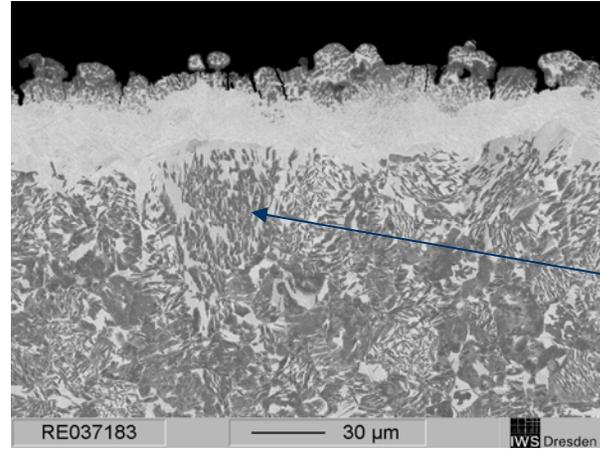
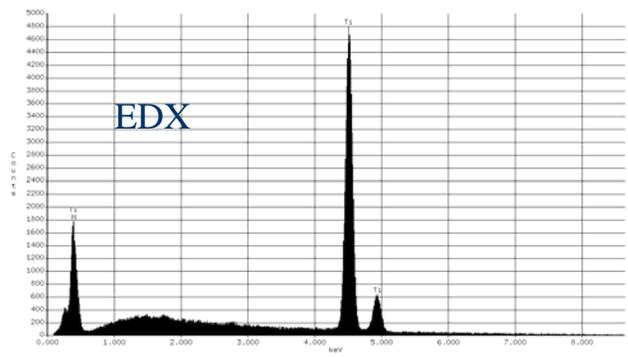
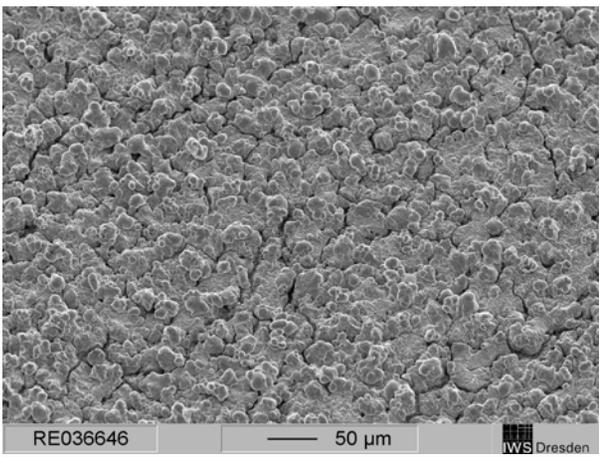
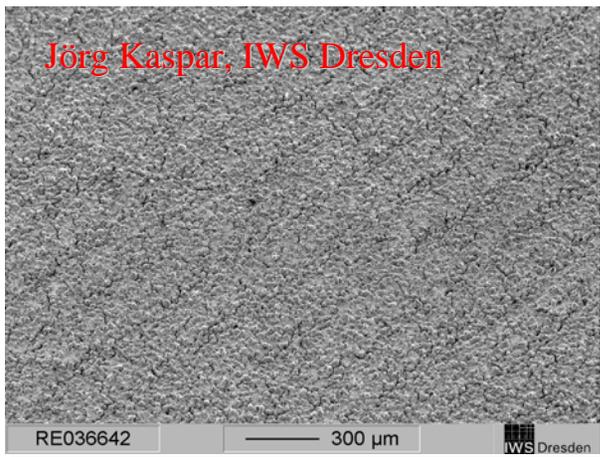


d5: 1000  $\mu$ s, 30 Hz, 100  $\mu$ m



d1: 1000  $\mu$ s, 10 Hz, 200 $\mu$ m

Jörg Kaspar, IWS Dresden



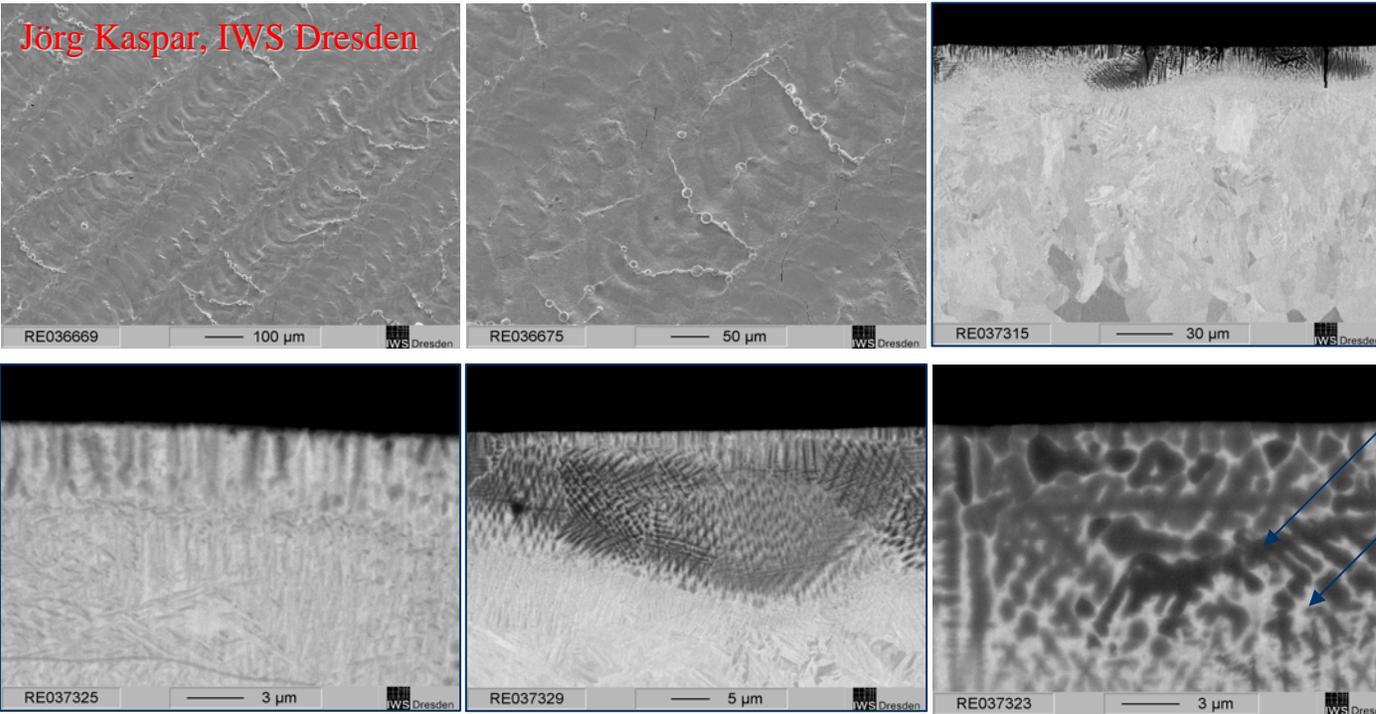
~ 23 at.% N

~ 16 at.% N

~ 8 at.% N

Surface very rough, melting pearls, network of fine cracks, melting depth 30-40  $\mu$ m, TiN 5-15  $\mu$ m, primary solidification of TiN at the surface, TiN has a nitrogen rich kernel and less nitrogen cover,  $\alpha'$ -Martensite in between

Jörg Kaspar, IWS Dresden



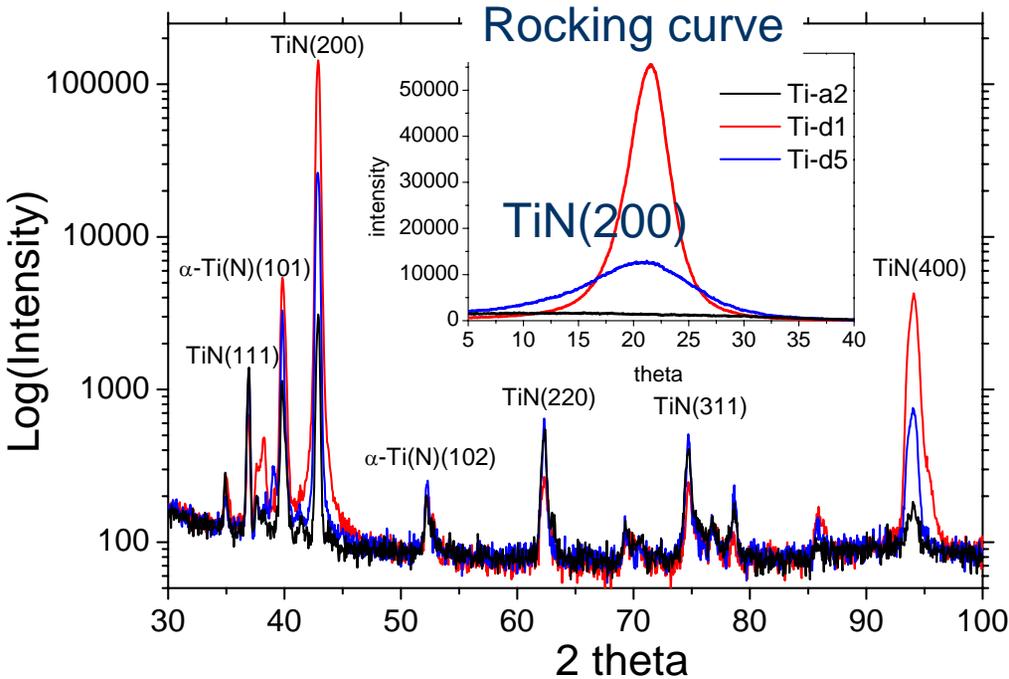
EDX: ~30 at% N

EDX: ~10 at% N

melting zone 20-30 $\mu$ m, TiN 0-25 $\mu$ m,  
 Very smooth surfaces, very few melt pearls, significant solidification  
 lines, fine cracks.  
 cracks only within TiN. TiN cover smaller.  
 TiN perpendicular to the surfaces, dendritic solidification



# GIXRD: Texture, Rocking curves



1000  $\mu$ s,  
10 Hz,  
200  $\mu$ m

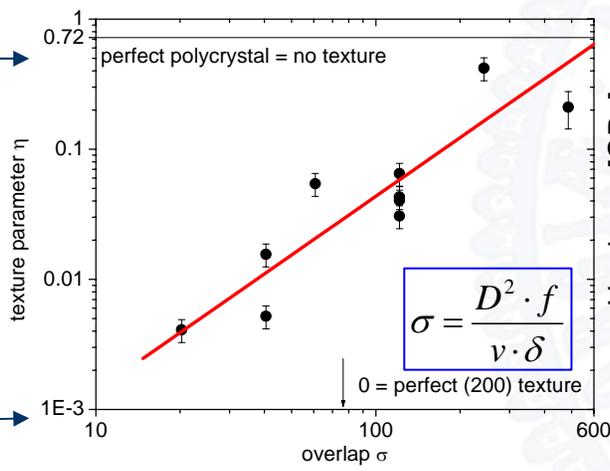
Strong texture for long macropulses and small overlap

1000  $\mu$ s,  
30 Hz,  
100  $\mu$ m

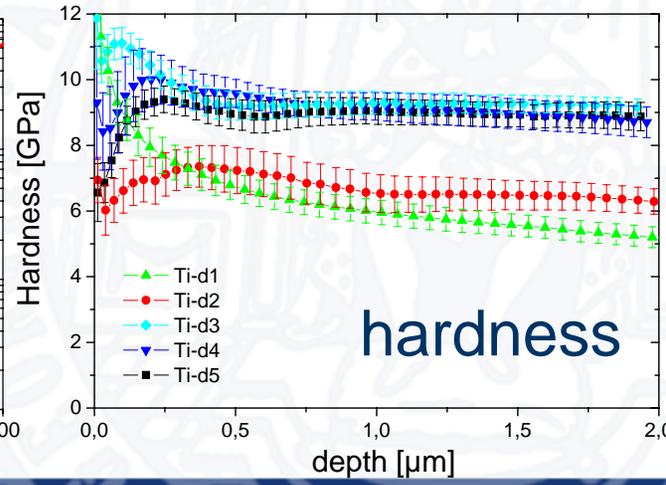
no texture for short macropulses and large overlap

250  $\mu$ s,  
60 Hz,  
100  $\mu$ m

no texture (polycryst.)  $\rightarrow$

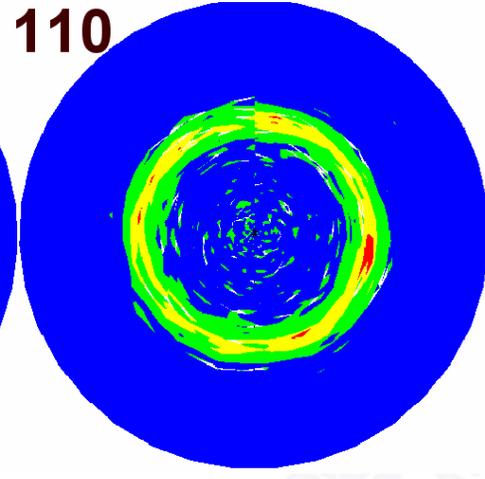
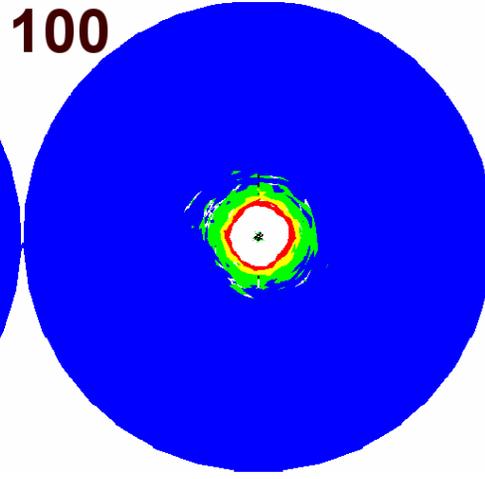
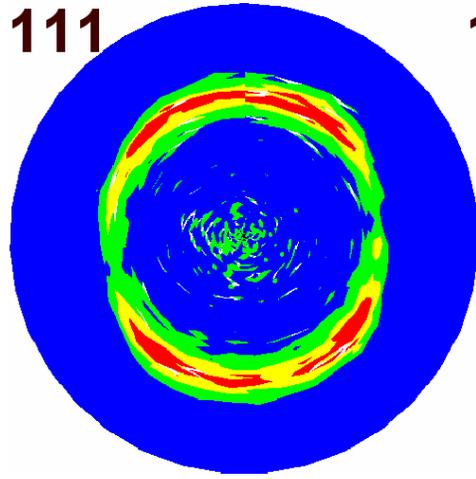


fully textured (single cryst.)  $\rightarrow$

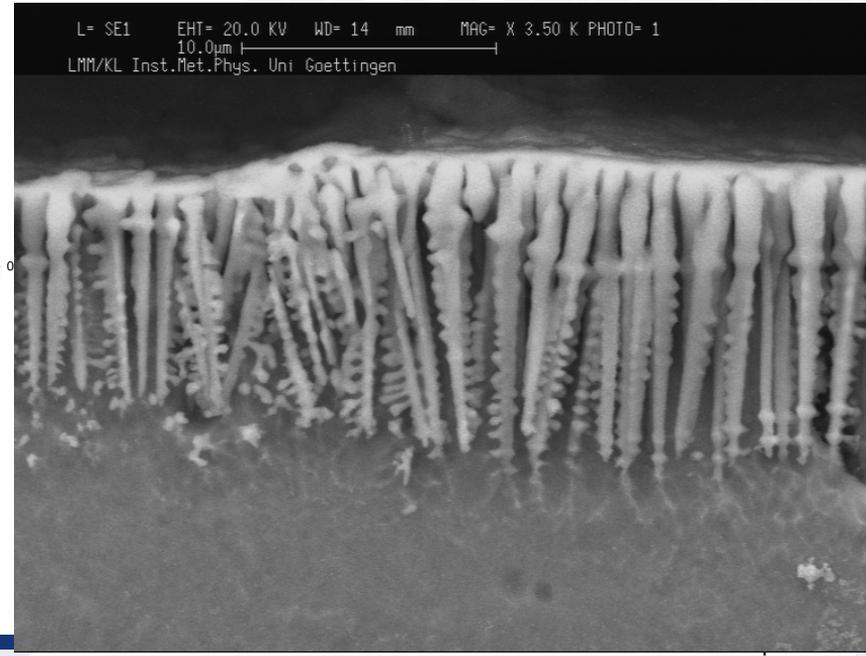
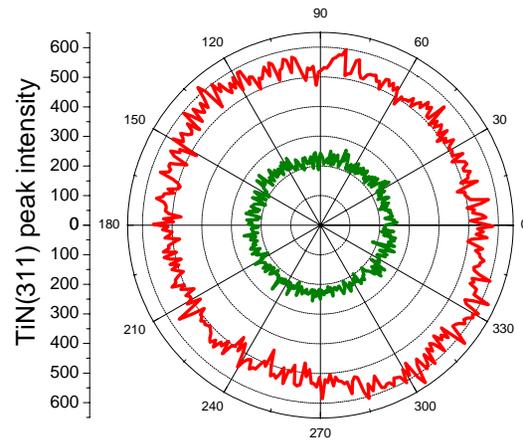
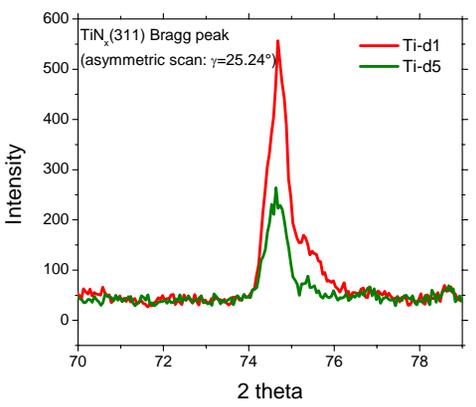




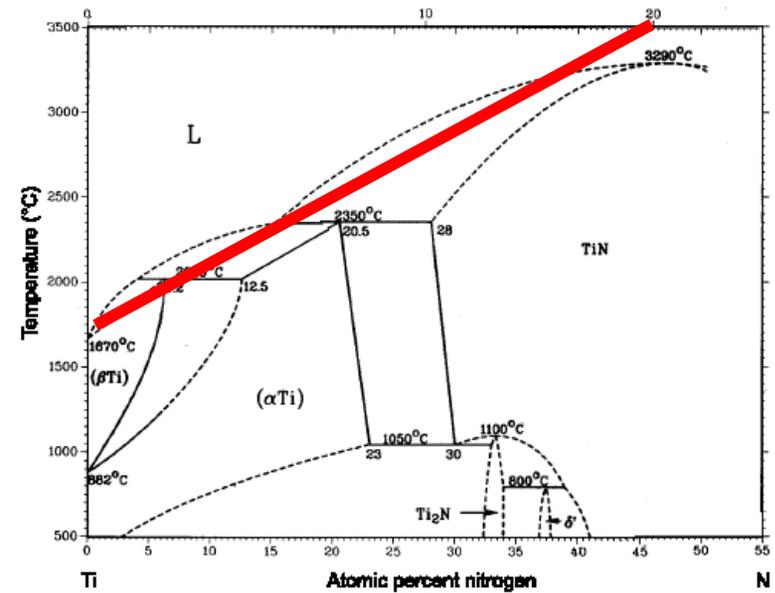
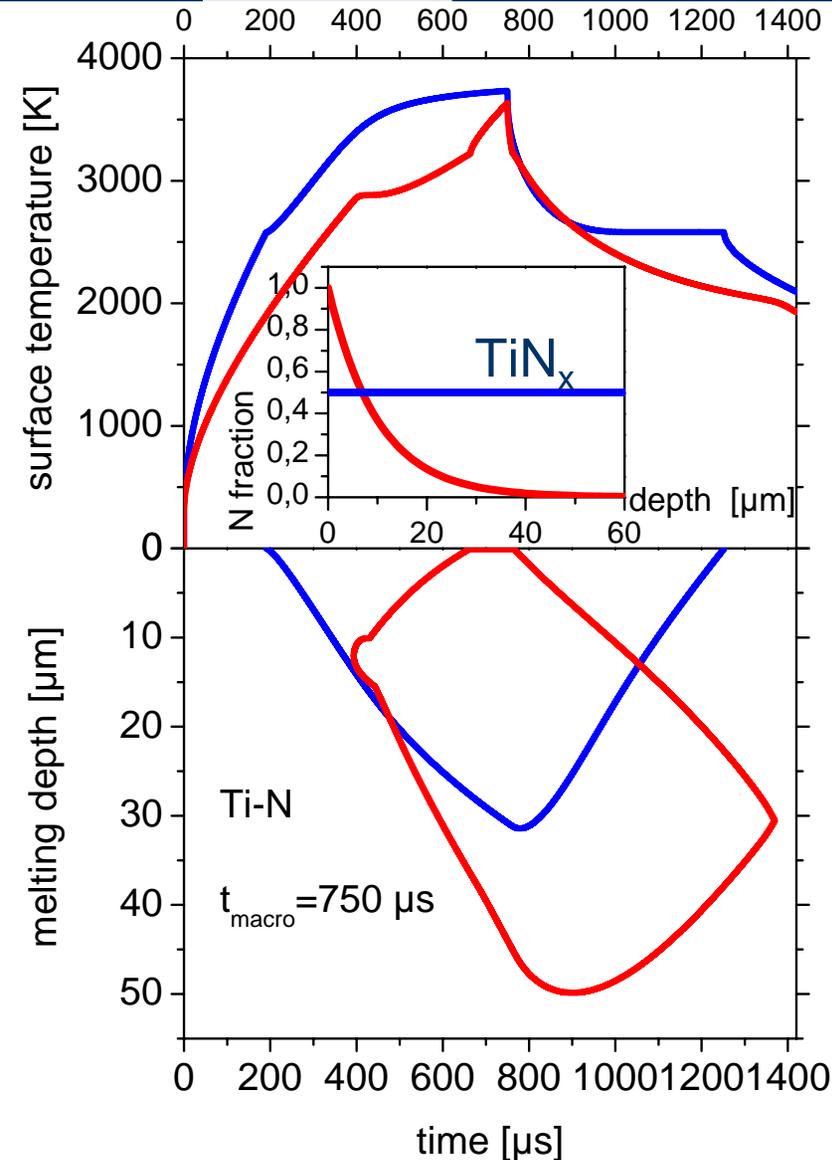
# FEL TiN: Pole Figures



Ti-d3 (Ti-25)  
 scan:  $5^\circ \times 5^\circ$   
 $\varphi$ : 0-360°  
 $\chi$ : 0-80°



Symmetric -> columnar growth, fiber texture  
 very strong texture, well aligned columns



Strong dependence of the melting temperature on the nitrogen content

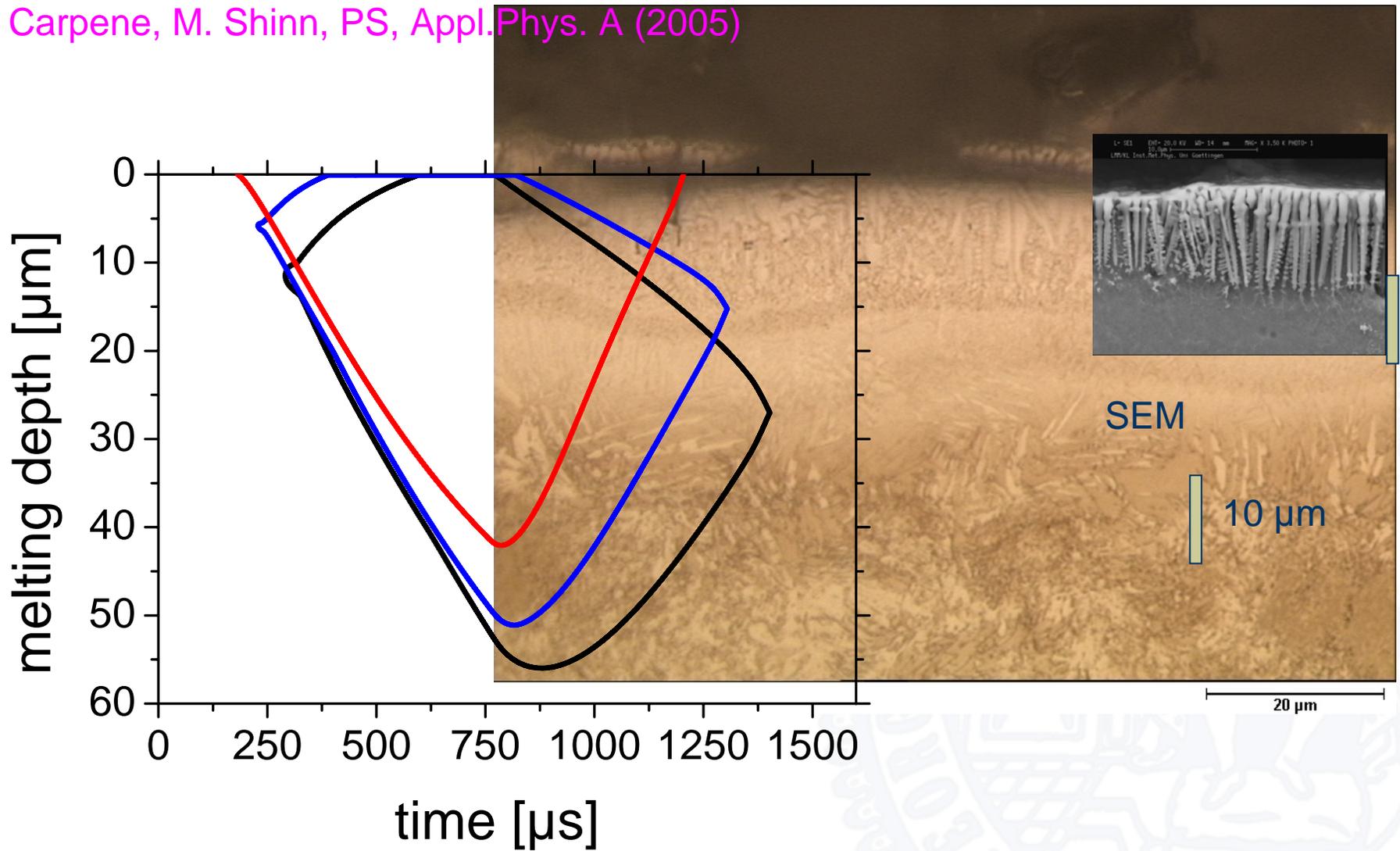
nitrogen concentration gradient:

re-solidification starts at surface

free (200) surface is most favorable

E. Carpene, PS, *MRS Proc.* **780** (2003) Y5.8.1

E. Carpene, M. Shinn, PS, *Appl.Phys. A* (2005)





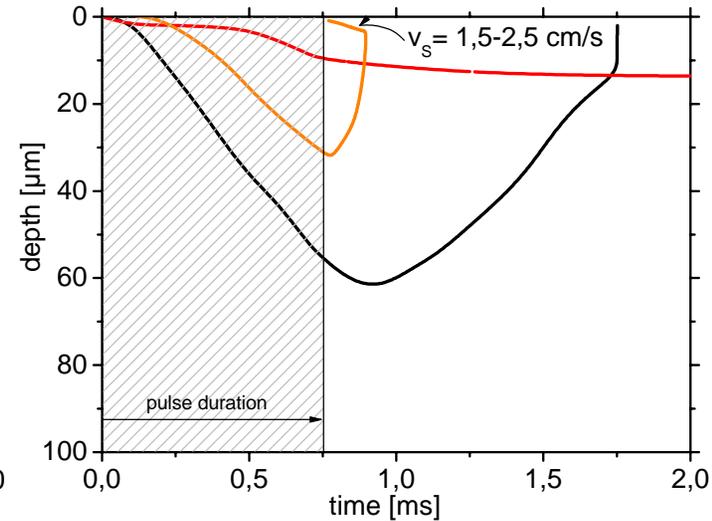
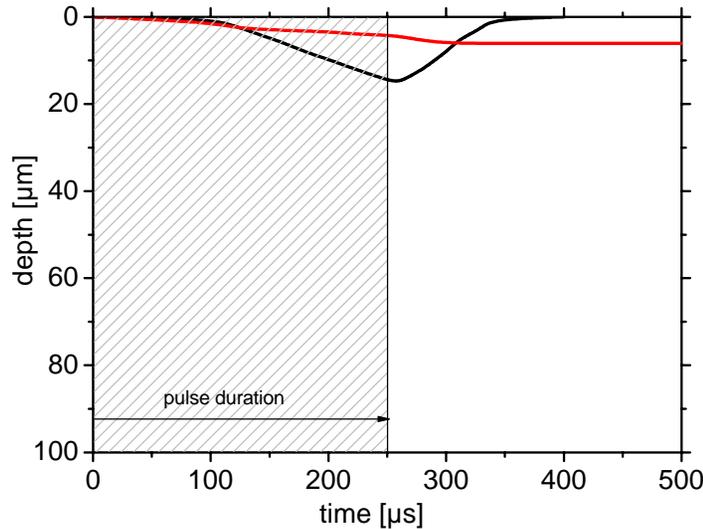
# FEM - Simulations

melting depth:

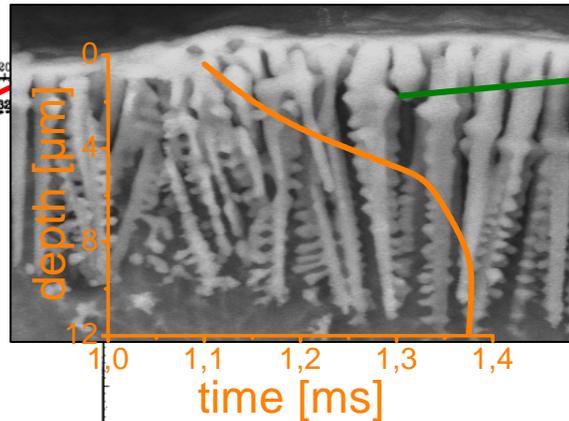
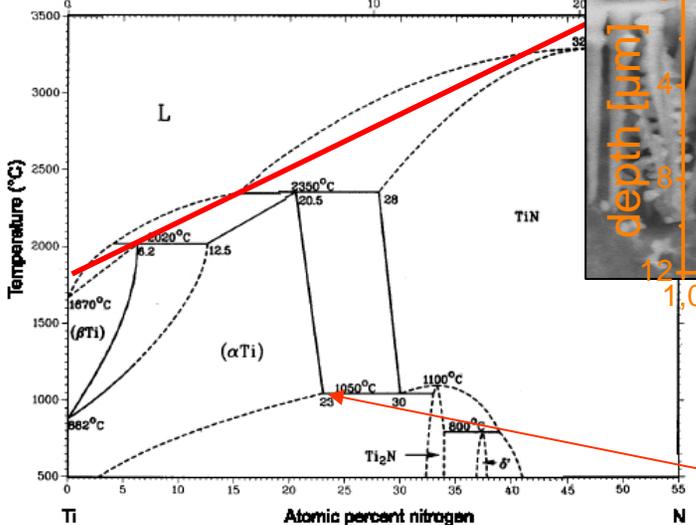
- Ti
- TiN

diffusion depth (1/e):

- 1 Pulse
- 2 Pulses
- 2 Pulses (corr.)

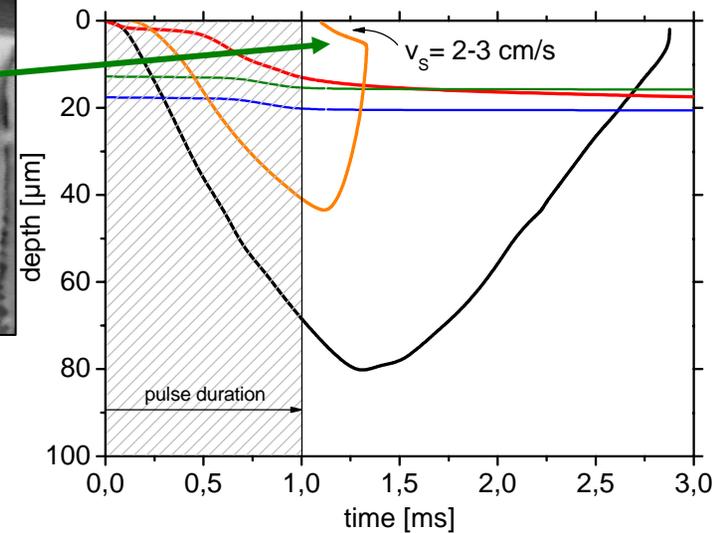


Phase diagramme:



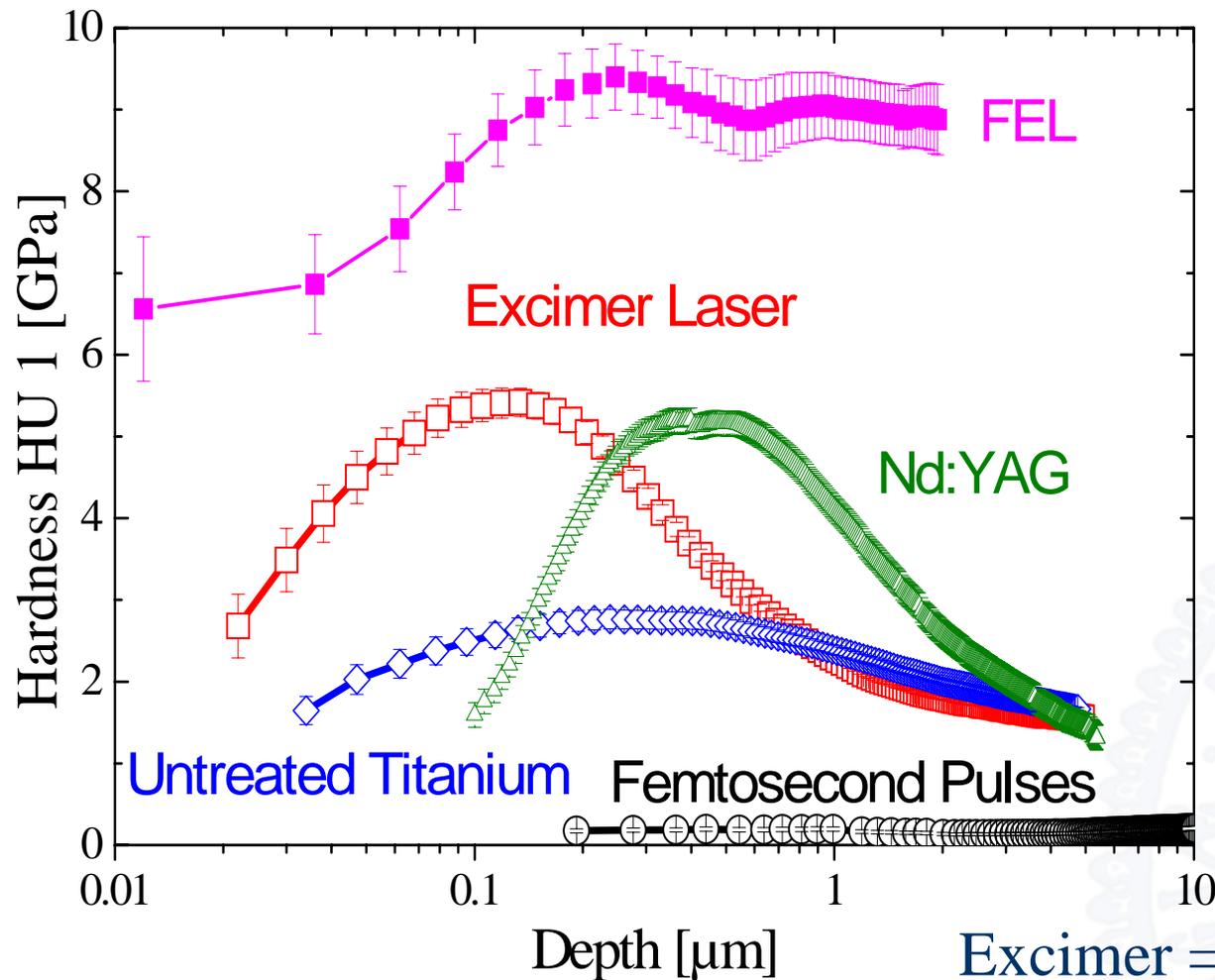
$$T_m = f(\text{N}\%)$$

23% solubility





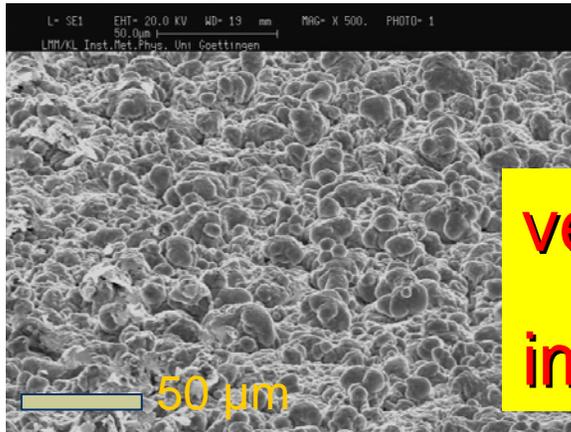
# TiN: hardness – comparison laser



Femtoseconds – very soft (nanocluster)

FEL highest hardness and thickest coating

Excimer = „smooth“ ( $R_a < 0.5 \mu\text{m}$ )  
Nd:YAG:  $R_a \sim 1-2 \mu\text{m}$   
FEL: smooth (cracks)



a2: 250  $\mu$ s, 60 Hz, 100 $\mu$ m

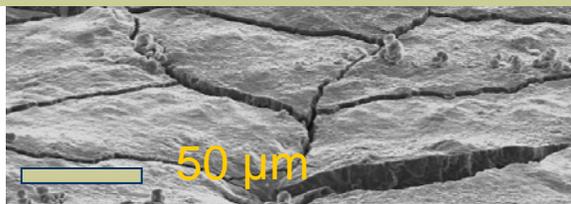


c1: 750  $\mu$ s, 30 Hz, 100 $\mu$ m

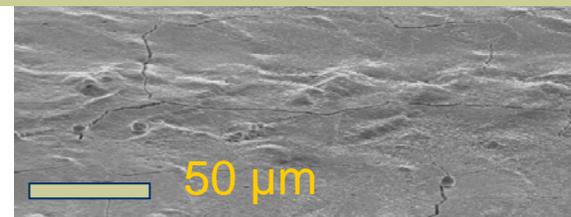
**very promising for  
implant surface structuring**

Kieswetter K, Schwartz Z, Hummert TW, Cochran DL, Simpson J, Dean DD, Boyan BD.  
Surface roughness modulates the local production of growth factors and cytokines by osteoblast-like MG-63 cells.

Journal of Biomedical Material Research 1996; 32 (1): 55-63.



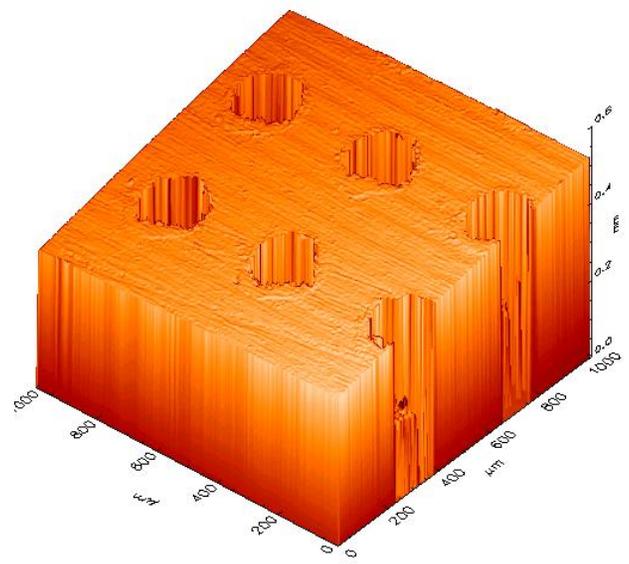
d5: 1000  $\mu$ s, 30 Hz, 100  $\mu$ m



d1: 1000  $\mu$ s, 10 Hz, 200 $\mu$ m



Laser-Structuring of an hip-joint



3D image of a laser structured hio joint (drilling holes of  $D=200 \mu\text{m}$ )

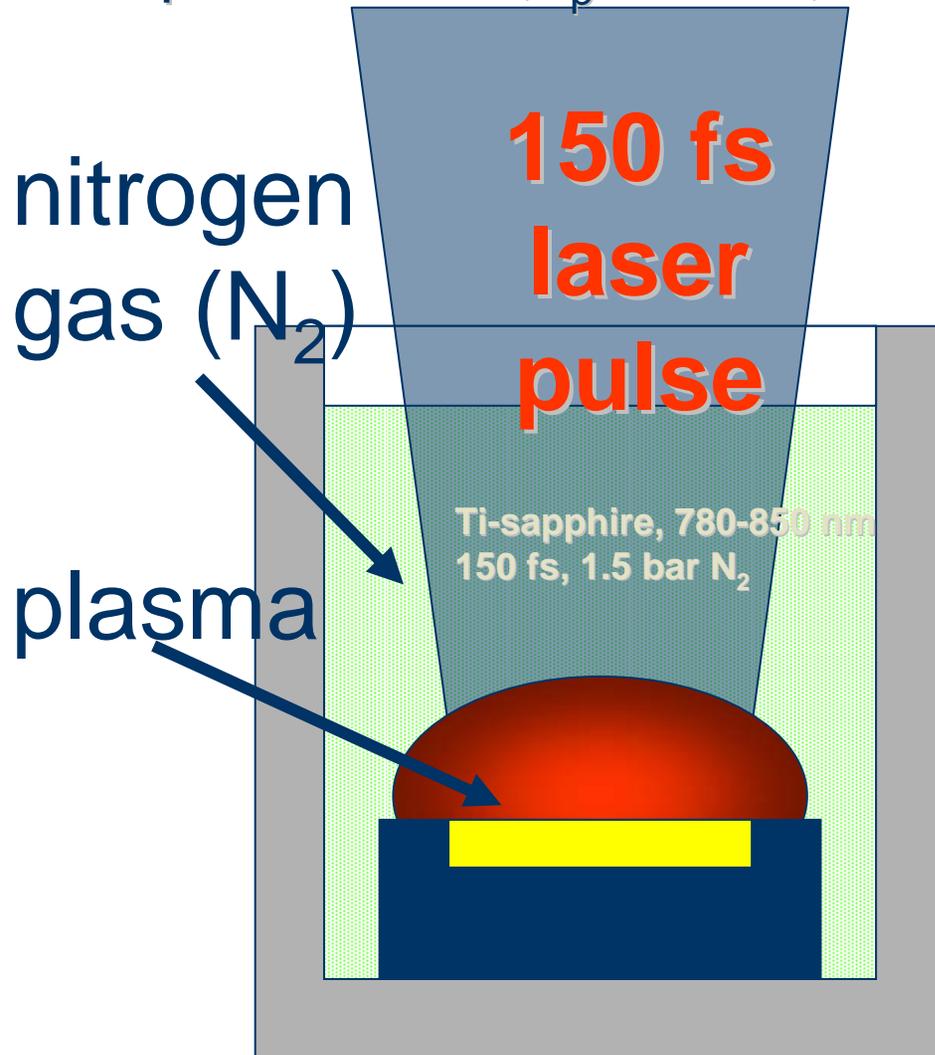


Aim: durable osseo-integration and implant stability

Way: Surface must be a good stimulus for bone ingrowth (good microcontacts=osseointegration) very stable bone-implant-connection

chemical modification for chemical resistivity

Ti:Saphir mit CPA,  $t_p=150$  fs,  $\lambda=800$  nm



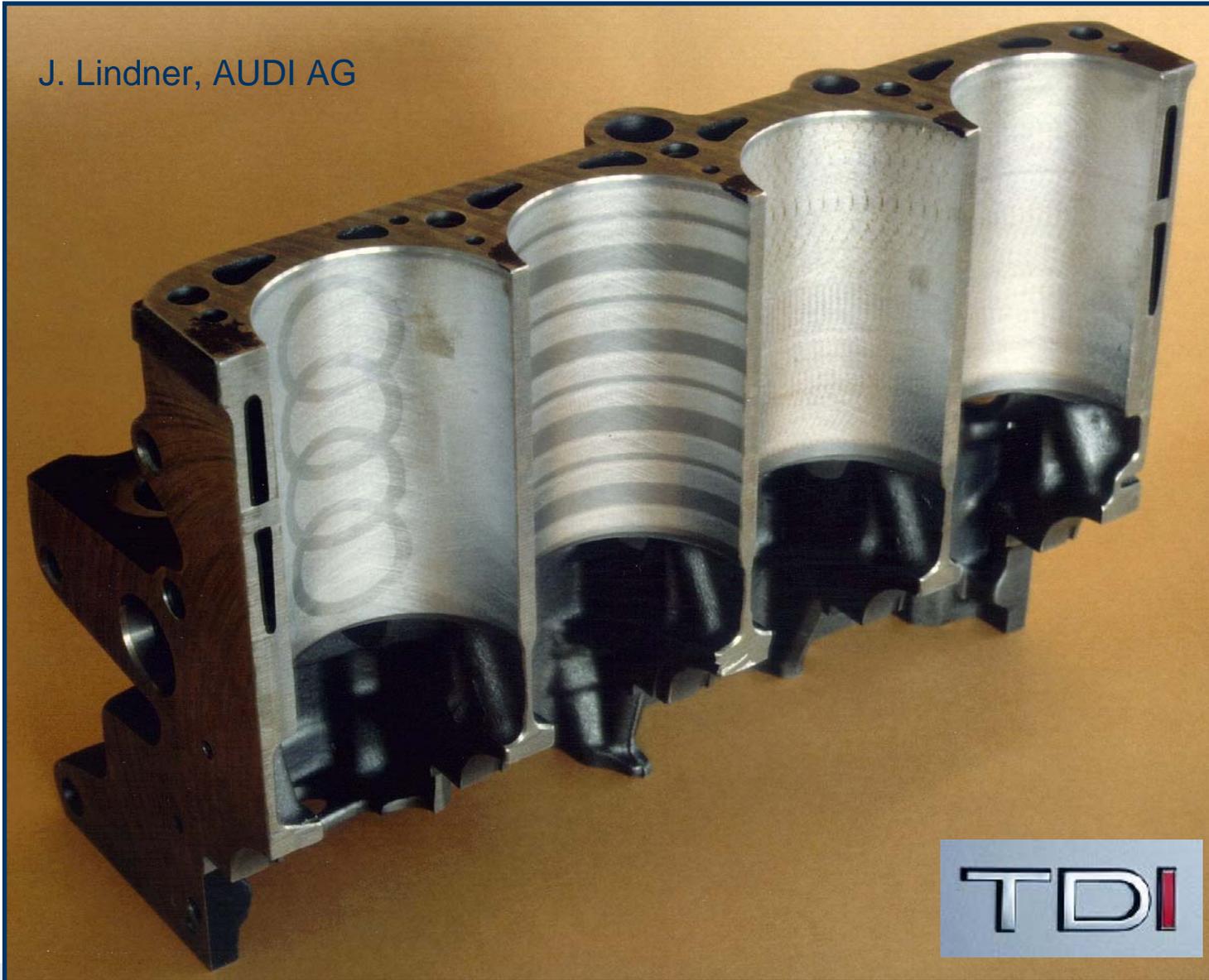
$t_p=1.5 \cdot 10^{-13}$  s (pulse duration):  
 $\Rightarrow$  non-thermal treatment  
 (Coulomb explosion)

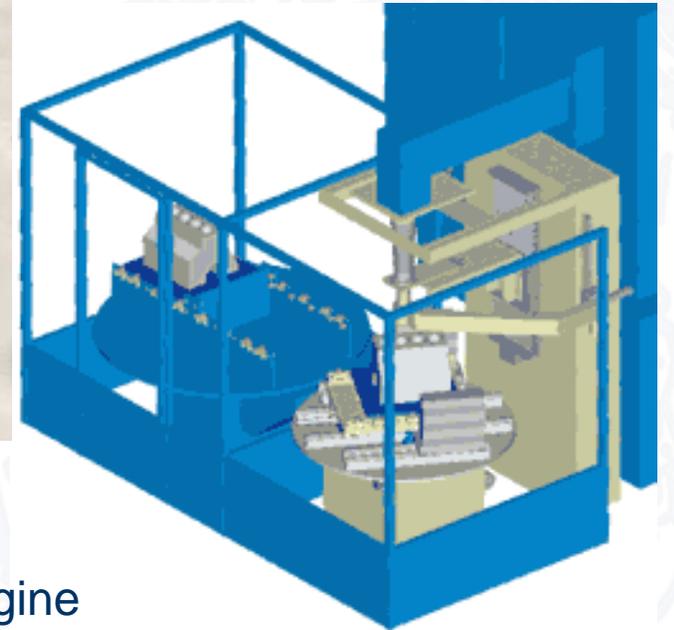
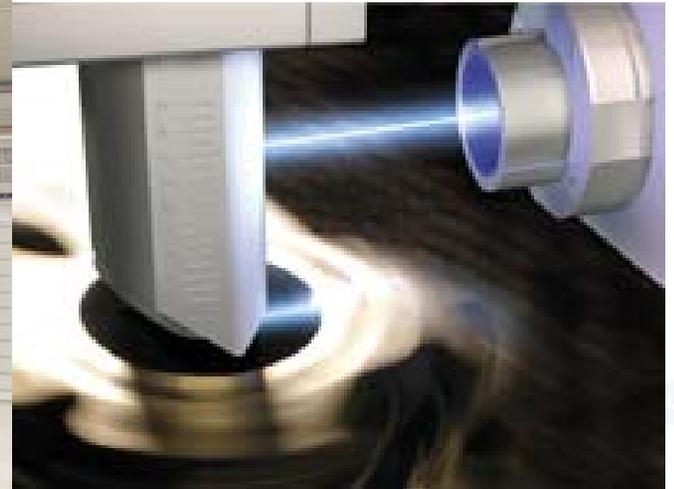
$$t_p \ll t_e \Rightarrow T_{\text{elec}} \gg T_{\text{latt}}$$

- affected depth  $\sim 10$  nm
- plasma only **after** laser pulse
- highly ionized vapor

# Industrial Applications

J. Lindner, AUDI AG



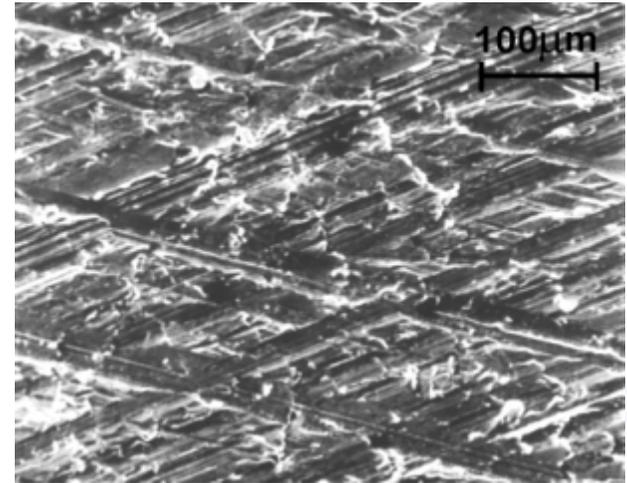


Treatment: mirror inside cylinder;  
rotating engine block,  
in series production, 5 Excimer simultaneous, 2 min/engine

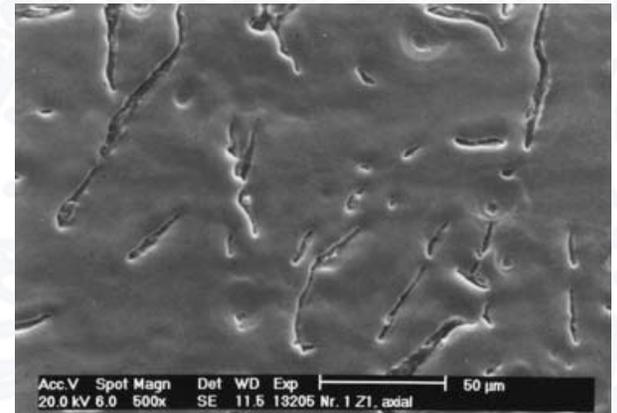




Fotos: Audi Schilling Spezialbeschichtungen GmbH (re.)

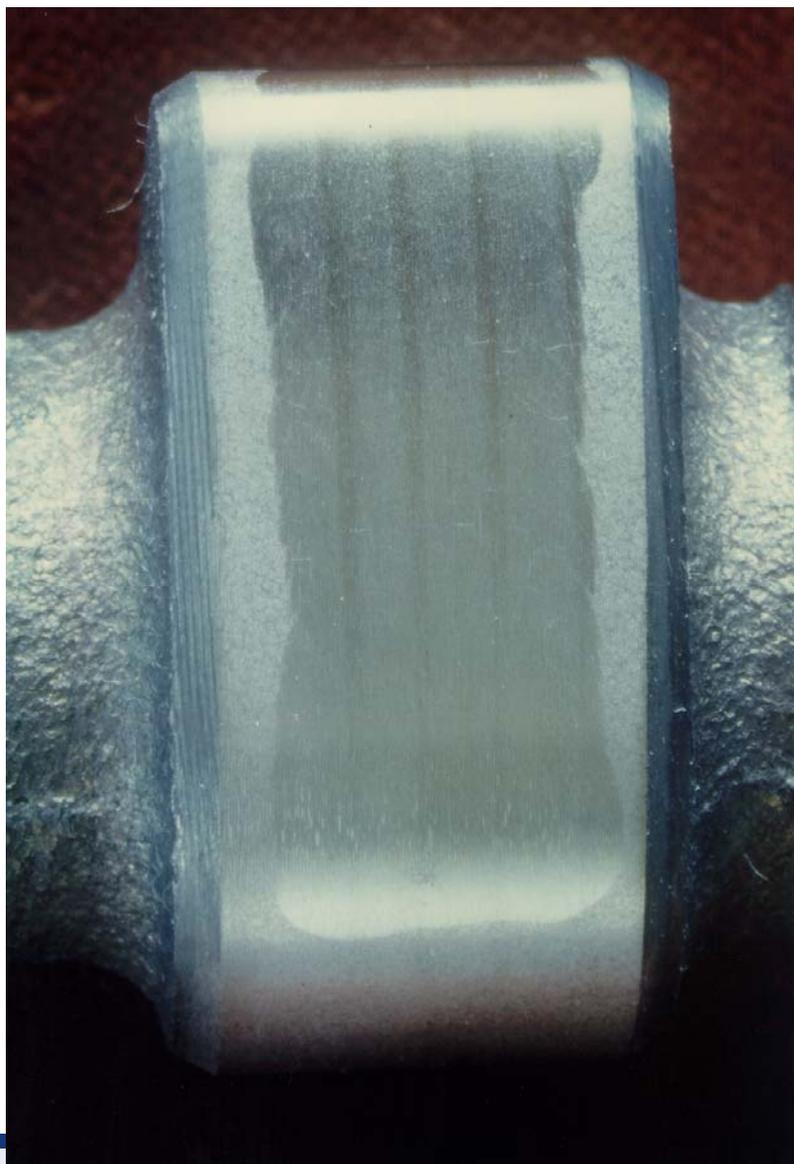
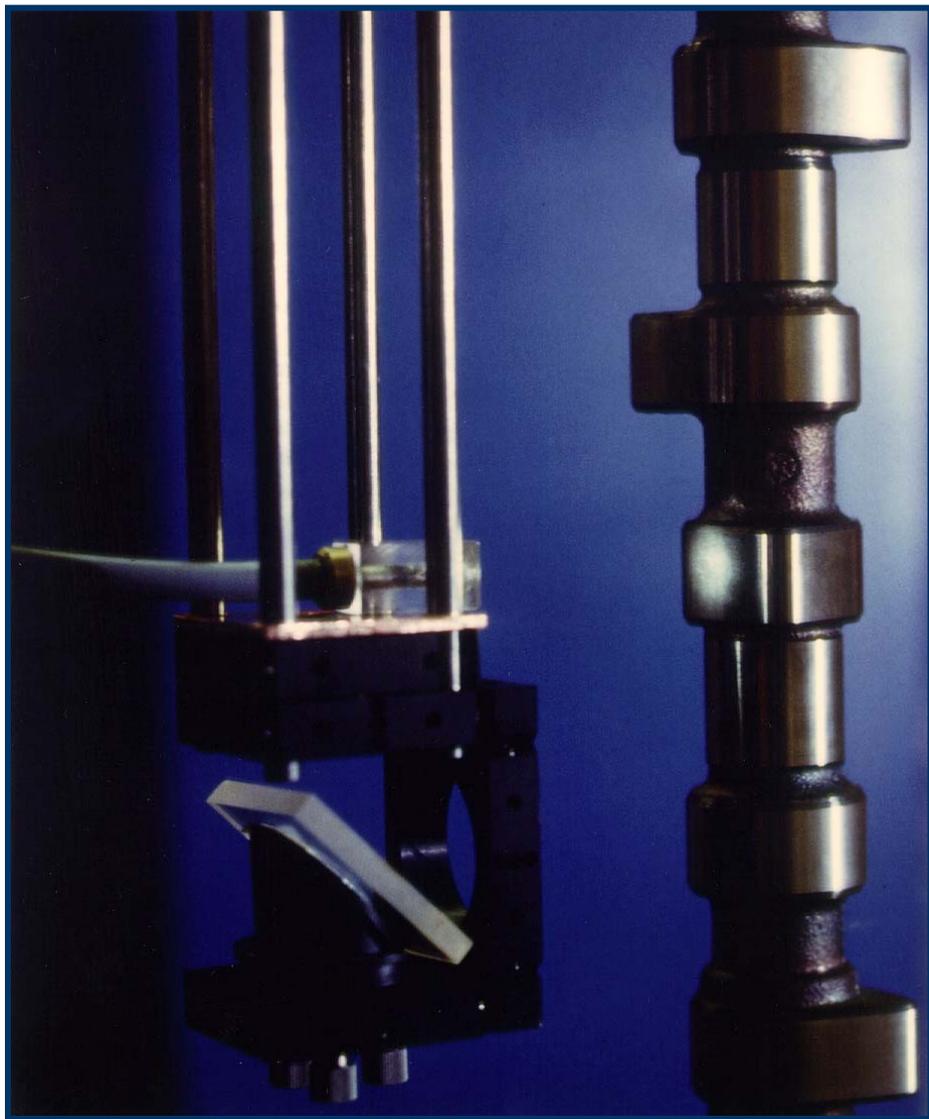


After honing



After laser treatment

Reduction of oil consumption (30x)  
increase in efficiency and power



# Summary



- Reactive Laser treatments enable flexible, clean and fast ways for the production of new materials, thin films and coatings
- Easy and fast modification and functionalizing of thin films and coatings by laser beams.
- But: sensitive adaptation of material, laser, and laser treatment for the specific application.
- Combination of several methods for resolving complicated processes and optimization of processing necessary.
- FEL is very attractive for fast (competitive) surface treatments
- Nanostructuring, Pulse tailoring
- Many Perspectives for thin films



- FEL, Jefferson Lab, Newport News, Virginia, USA
- AUDI AG, Daimler Benz, INA Wälzlager, IBM, Stihl
- Prof. H.-W. Bergmann (†), Uni Bayreuth, Metall. Werkstoffe
- Prof. A. Emmel, FH Amberg-Weiden, FB Maschinenbau
- Prof. M. Bamberger, Dr. W.D. Kaplan, Technion Haifa, Israel
- Prof. J. Wilden, TU Ilmenau, Fertigungstechnik
- BIAS Bremen, LZH Hannover
- Fraunhofer ILT, IPT, RWTH Aachen
- IWT, IWS Dresden, MPI Halle
- LURE Paris, ESRF, Grenoble, BESSY, ANKA
- Prof. H.-J. Spies, TU Freiberg, Werkstoffkunde
- Prof. M. Somers, TU Kopenhagen, Materials Science
- Prof. E. Mittemeijer, Dr. G. Dehm, MPI Stuttgart
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- Co-workers and Group:

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A. Müller, F. Landry, M. Han, S. Wagner,  
C. Illgner, S. Dhar, S. Cusenza,

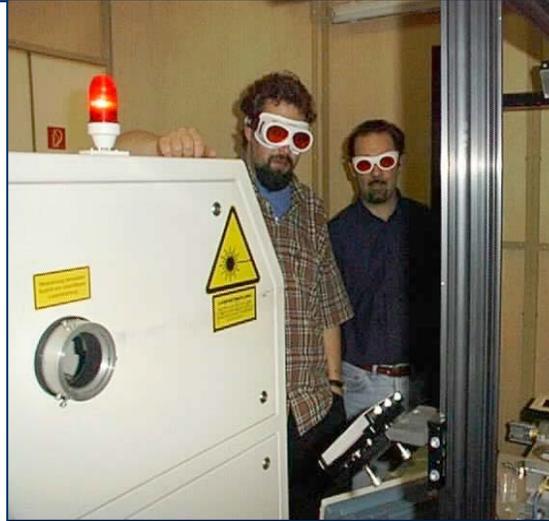
IWT Dresden: J. Kaspar

FH Amberg: A. Emmel, R. Queitsch

- FEL@Jefferson Lab:

Fred Dylla, Gwyn Williams, Jo Gubeli,  
Kevin Jordan

- **Your interest and patience**





# You are welcome to visit Göttingen

